

	L #	Hits	Search Text	DBs
1	L1	489297	(multilayer\$4 or layer\$4 or film).ti,ab.	US- PGPUB; USPAT
2	L2	49232	etch\$4.ti,ab.	US- PGPUB; USPAT
3	L4	173616	selectiv\$6.ti,ab.	US- PGPUB; USPAT
4	L5	35103	plasma.ti,ab.	US- PGPUB; USPAT
5	L6	673	1 and 2 and 4 and 5	US- PGPUB; USPAT
6	L7	4917	2 near3 4	US- PGPUB; USPAT
7	L8	447	1 and 5 and 7	US- PGPUB; USPAT
8	L9	239403	(optical or lens or grating or fresnel).ti,ab.	US- PGPUB; USPAT
9	L10	10	8 and 9	US- PGPUB; USPAT
10	L11	103312	(stack\$4 or multilevel or multilayer\$4 or multi adj (layer\$4 or level) or multiple adj (layer\$4 or film)).ti,ab.	US- PGPUB; USPAT
11	L12	48	7 and 11 and 5	US- PGPUB; USPAT
12	L13	79156	(silicon or si).ti,ab.	US- PGPUB; USPAT
13	L15	17763	(silicon adj (oxide or dioxide) or "sio.sub.2").ti,ab.	US- PGPUB; USPAT
14	L16	339	7 with 5	US- PGPUB; USPAT
15	L17	78	13 and 15 and 16	US- PGPUB; USPAT

	L #	Hits	Search Text	DBs
16	L18	28	9 and 11 and 7	US- PGPUB; USPAT
17	L19	304741	plasma	US- PGPUB; USPAT
18	L20	11	18 and 19	US- PGPUB; USPAT
19	L21	1452	430/321.ccls.	US- PGPUB; USPAT
20	L22	2	5 and 7 and 21	US- PGPUB; USPAT
21	L23	0	7 and 11 and 21	US- PGPUB; USPAT
22	L24	12	7 and 1 and 21	US- PGPUB; USPAT
23	L25	4	2 and 11 and 21 and 19	US- PGPUB; USPAT
24	L26	871	216/24,26.ccls.	US- PGPUB; USPAT
25	L27	16	11 and 26 and 19	US- PGPUB; USPAT
26	L28	18	7 and 26 and 19	US- PGPUB; USPAT
27	L29	2129	216/67.ccls.	US- PGPUB; USPAT
28	L30	81	9 and 29	US- PGPUB; USPAT
29	L31	3	30 and 7	US- PGPUB; USPAT
30	L33	33	dierichs-marcel\$.in.	US- PGPUB; USPAT

	L #	Hits	Search Text	DBs
31	L34	114	loopstra-erik\$.in.	US- PGPUB; USPAT
32	L35	37	(33 or 34) and (9 or 7 or 5)	US- PGPUB; USPAT
33	L36	23615	etch\$4 near3 selectiv\$6	EPO; JPO; DERWE NT; IBM_TDB
34	L37	205068	plasma	EPO; JPO; DERWE NT; IBM_TDB
35	L38	402707	(stack\$4 or multilevel or multilayer\$4 or multi adj (layer\$4 or level) or multiple adj (layer\$4 or film))	EPO; JPO; DERWE NT; IBM_TDB
36	L40	250	36 and 37 and 38	EPO; JPO; DERWE NT; IBM_TDB
37	L41	1366504	(optical or lens or grating or fresnel)	EPO; JPO; DERWE NT; IBM_TDB
38	L42	13	40 and 41	EPO; JPO; DERWE NT; IBM_TDB

	L #	Hits	Search Text	DBs
39	L43	62706	(silicon adj (oxide or dioxide) or "sio.sub.2")	EPO; JPO; DERWE NT; IBM_TDB
40	L44	1752113	silicon or si	EPO; JPO; DERWE NT; IBM_TDB
41	L45	33	40 and 43 and 44	EPO; JPO; DERWE NT; IBM_TDB